



ISC Audits & Reviews SC Summary March 2016

Doc. #	Title	Results
5229B	Revision to SEMI P44, Specification for Open Artwork System Interchange Standard (OASIS) Specific to Mask Tools	Passed
5906	Line Item Revision to SEMI P39-0308, OASIS (TM), Open Artwork System Interchange Standard (To correct nonconforming title)	
LI1	Line Item 1 - Correct the title of this standard for conformance by adding the word "Specification for"	Passed
5907	Revision to SEMI P5-0704, Specification for Pellicles	Passed
5908	Reapproval for SEMI P40-1109, Specification for Mounting Requirements for Extreme Ultraviolet Lithography Masks	Passed
5909	Reapproval for SEMI P48-1110, Specification of Fiducial Marks for EUV Mask Blank	Passed
R5495	Ratification Ballot, New Standard: Guide for CycloHexanone	Passed
R5658A	Ratification Ballot, New Standard: Guide for PENTAKIS(DIMETHYLAMINO) TANTALUM (PDMAT)	Passed
R5765	Ratification Ballot, Revision to SEMI C15, Test Method for ppm and ppb Humidity Standards	Passed

Line Item (LI)

For more information, please contact the SEMI Standards Engineer/Coordinator (<http://www.semi.org/standards/contacts>) nearest you.

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March 16, 2016